

Nanoscale Measurement of Surface Roughness and the existing Surface Forces of Aluminum by AFM

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Abstract

The surface contamination affects Atomic Force Microscope (AFM) performance. Thermal agitation during mapping doping, thermal oxidation, annealing impurities and crystal defects promotes the roughness, various kinds of forces on the surface can be detected by the interaction between tip of cantilever and sample. This interaction not only help us to understand the characteristics and morphology of the sample but also useful to measure the surface force of the aluminum sample too.

1. Introduction

Aluminum is a silvery white member of the boron group of chemical element. It is not soluble in water under normal circumstances. Aluminum is the third most abundant element, after oxygen and silicon. It makes up about 8% by weight of the Earth's solid surface [1]. Aluminum has very good ductility and the malleable property therefore, it has wide range of application in the present world in various field like in Building, in Transportation, in production Engineering, in Electronics, in Household etc [2].

In the last decade there has been an increasing interest in mesoscopic devices in which the size of the active elements is in nanoscale (between 1 nm and 100 nm). Peculiar physical phenomena like the coulomb blockade and the quantization of the conductance emerge at this length scale, and their study is relevant to the design of novel nanoelectronic devices [3]. Surface roughness and surface force, can be analyzed by the AFM. In contact mode, tip of cantilever is scanned at a constant height. To prevent a risk that the tip collide with the sample surface and get damaged, feedback mechanism is employed to adjust the tip-to-sample distance to maintain a constant force between the tip and the sample. Now laser light from a solid state diode is reflected off the back of the cantilever and collected by a position sensitive detector (PSD) consisting of two closely spaced photodiode whose output signal is collected by a differential amplifier. From this output topography of the gives sample can be developed. The forces that are measured in AFM

include van der Waals forces, capillary force, chemical bonding, electrostatic forces, magnetic forces, Casimir forces, salvation forces etc [4]. The topography along the X-Y plane, the observed van der Waals force against the cantilever deflection along the Z-axis (force distance curve) gives morphological, spectroscopical as well as dynamical behavior of the sample at the different molecular region.

Experimental Details and Results

Calculation of the surface roughness

Then aluminum sample is observed through the AFM.

Prepared sample is examined by AFM. What we found is that deflection of the cantilever is not uniform over the regions of the sample surface [5]. Here, we take the root mean square roughness value which is given by the formula,

$$R_{rms} = \sqrt{\frac{\sum_{i=1}^n (Z_i - \bar{Z})^2}{n}}$$

Where Z_i is the height of each data point, \bar{Z} is the average of all height values in the image and n is the number of data points within the image [6]. The three dimensional image and the observed roughness of the given aluminum sample and retract mode are shown in figure 2 (a), 2 (b), Graph 2 (c) and Graph 2 (d).

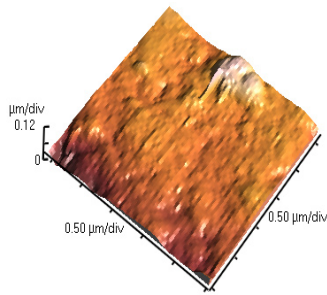


Fig.1 (a) 3D image of aluminum sample approach mode

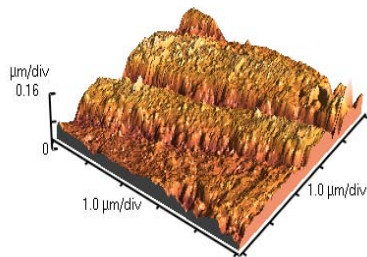


Fig.1 (b) 3D image of aluminum sample in in retract mode

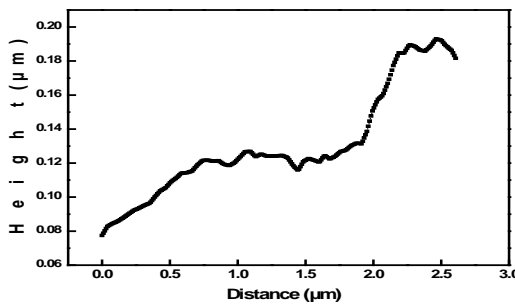


Fig. 1 (c) surface roughness of aluminum in approach mode

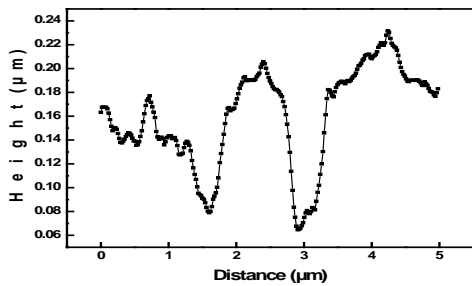


Fig. 1 (d) surface roughness of aluminum in contract mode

From the graph 1 (c) and 1(d), the calculated root mean square roughness of the aluminum in approach mode and retreat mode is found to be $R_{rms1} \cong R_{rms1} \cong 0.13$ Micrometer and $R_{rms2} \cong R_{rms2} \cong 0.15$ Micrometer respectively. Hence from the above calculation, we found that aluminum in approach mode have more smooth surface than in retract mode.

Calculation of surface force (pull-off -force)

When the tip of the cantilever is mounted on the surface of the sample, force curve is collected by monitoring vertical cantilever deflection and the interaction between tip of cantilever and sample .The cantilever deflection can be converted to applied force through the cantilever spring constant, (k_N) by the equation 1 given by the Hook’s law [7];

$$F_N = K_N \Delta Z \quad F_N = K_N \Delta Z \dots\dots\dots 1$$

Let, if cantilever have the length (L), width (w), thickness (t) and the Young modulus (Y), then for the normal deflection, the spring constant of the cantilever is given by the equation 2[8].

$$K_N = \frac{1}{4} Y \frac{wt^3}{L^3} \quad K_N \dots\dots\dots 2$$

The work required to separate surface 1st and surface 2nd in the medium 3rd is called the surface energy. It is also called work of adhesion and is related to the interfacial energies.

The work required separating surface 1st and surface 2nd in the medium 3rd per unit area is given by equation 3.

$$W_{132} = \gamma_{13} + \gamma_{23} - \gamma_{12} \dots\dots\dots 3.$$

Where γ is interfacial energy, 1 and 2 represents the two surfaces, and 3 refer to the contracting medium. When measurements are performed between symmetric contacts (i. e., $\gamma_1 = \gamma_2$) in medium 3, equation 3 becomes.

$$W_{131} = 2\gamma_{13} \dots\dots\dots 4.$$

If measurements are performed in a vacuum or in inert gas , the interfacial free energy γ_{13} is simply the surface energy, γ_1 . In this case, W_{132} reduces to W_{12} , which represents the work of adhesion for an asymmetric contact and is equal to $\gamma_1 + \gamma_2 - \gamma_{12}$.

The adhesive force from DMT theory is given by

$$F_{ad} = 2\pi RW_{132} \dots\dots\dots 5.$$

Again the adhesive force given by the JKR theory is given by the equation;

$$F_{ad} = 1.5\pi RW_{132} \dots\dots\dots 6.$$

These formulations provides a basis for relating the work of adhesion and the interfacial energies to the adhesion forces obtained by micro contact experiment i. e., the pull-off portion of

the force. The force curve can be divided into several regions as shown in Figure 2 (e).

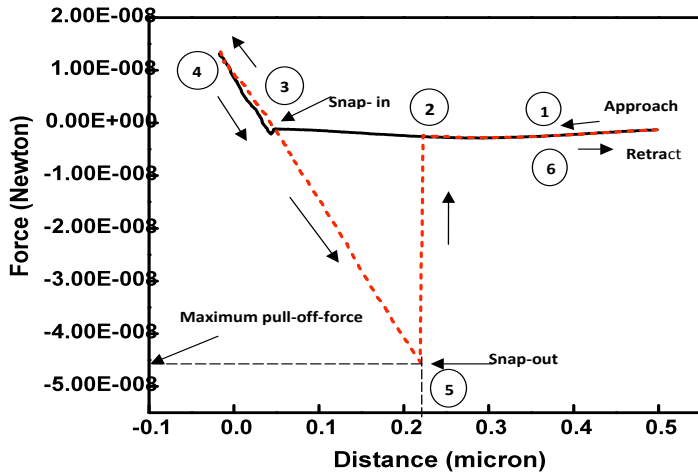


Figure 1 (e) Force Vs Distance Curve of the Aluminum Sample

- (1) The tip sample is sufficiently separated such that there is no detectable interaction. At this distance cantilever is in its no interacting equilibrium position.
- (2) As the separation distances decreases, various long range and the short range forces come into existence which are given in the table below.

Table 1. Types of Interaction Forces and Distances.

Type	Distances (nm)	Note
Long range		
Electrostatic force in air	100	Depends on electrolyte concentration
Double layer force in electrolyte solution	100	
Van der Wall force	10	
Short range		
Surface induced solvent ordering	5	Depends on the molecular size of the solvent
Hydrogen bonding	0.2	
force contact	0.1	

These forces include attractive/repulsive electrostatic interaction, which are the result of the electrical double layer formed in aqueous electrolyte, and van der Wall interactions. At very small separations in liquid media, surface-induced solvent ordering may be detected.

- (3) As the separation decreases further, the gradient of the interaction force exceeds the force constant of the cantilever and the tip jumps into contact with the surface.
- (4) The tip and the sample are in contact, including a positive deflection of the cantilever. It is in this region that elastic properties of the sample can be measured.
- (5) Because of the adhesion between the tip and sample, a negative deflection of the cantilever is detected until the adhesive force is overcome by the restoring force of the cantilever and the contact ruptures. The magnitude of this negative deflection is related to the adhesion force, F_{ad} , of the micro contact. This adhesion is also referred to as rupture force of pull-off force.
- (6) The tip and the sample are sufficiently separated such that the cantilever returns to its no interaction equilibrium position.

Figure 1 (e) represents an ideal force curve when an adhesive contact is formed between the tip and sample (e. g., adhesion due to capillary forces when operating in air)[9].

From the Figure 1 (e) the maximum value of the pull-force of aluminum sample is found experimentally as

Pull-off force, $F_{pull-off} = -4.50 \times 10^{-8}$ Newton

Conclusion

In AFM experiment, the cantilever deflection is very sensitive for the measurement of the topography and the interaction between tip and sample. Cantilever deflection can also depend on the surface roughness of the sample, more the surface roughness more will be the deflection and vice versa. The adhesion force or the maximum pull-off force is inversely proportional to the sixth power of cantilever deflection or the tip-sample separation and experimentally calculated value is **Pull-off force, $F_{pull-off} = -4.50 \times 10^{-8}$ Newton** equilibrium distance (at which all the forces balance each other and there is no any forces affecting the cantilever deflection) is approximately found to **0.22 micron**. Hence certain laws of the physics (force distance curve) can be verified experimentally.

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